

19. (New) Method of making an electroconductive pattern on a support comprising the steps of:

- providing a material for making an electroconductive pattern, said material comprising a support and a light-exposure differentiable element, wherein said light-exposure differentiable element comprises an outermost layer containing a polyanion and a polymer or copolymer of a substituted or unsubstituted thiophene, and optionally a second layer contiguous with said outermost layer; and wherein said outermost layer and/or said optional second layer contains a light-sensitive component capable upon exposure of changing the removability of the exposed parts of said outermost layer relative to the unexposed parts of said outermost layer, said light-sensitive compound selected from the group consisting of a multidiazonium salt, a resin comprising a diazonium salt and a quinonediazide compound;
- image-wise exposing said material thereby obtaining a differentiation of the removability, optionally with a developer, of said exposed and said non-exposed areas of said outermost layer;
- processing said material, optionally with said developer, thereby removing areas of said outermost layer; and
- optionally treating said material to increase the electroconductivity of said non-removed areas of said outermost layer.

REMARKS

The Pending Claims

Claims 1-17 are currently pending. Claims 1-12 and 18 are directed to a material for making an electroconductive pattern. Claims 13-15 and 19 are directed to a method of making an electroconductive pattern on a support. Claims 16-17 are directed to a method of making an electroconductive pattern on a support without a removal step. Reconsideration of the claims is respectfully requested.